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| INFORMATION DISCLOSURE STATEMENT BY APPLICANT PTO FORM 1449 | ATTY. DOCKET NO. 10191/1629 | SERIAL NO. Not yet assigned 01 |
| | APPLICANT(s) Franz LAERMER et al. | |
| | FILING DATE Herewith | GROUP Not yet assigned |

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| EXAMINER K. C. G. J. L. H. | DATE CONSIDERED / 0-9-02 |
| EXAMINER: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant. | |